



IP Facilitation Center (IPFACE)
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Half-Day Workshop on Recent Major Changes in US Patent Law (Leahy-Smith America Invents Act)

LEARN	<ul style="list-style-type: none">• Background on US Patent Law and Procedures• Overview- America Invents Act• Key features and changes to the law<ul style="list-style-type: none">○ First to file system○ Post grant review○ Fee related provisions○ Prioritized examination○ Best mode changes○ Others• Implications and new filing/ prosecution strategies
FOR WHOM	<ul style="list-style-type: none">• Companies/organizations/ inventors filing patents in the US• IP professionals / patent agents• Staff of IP/ technology management departments• Advocates/ law firms/ LPOs/ KPOs• Students of law/IP law/pharma/ biopharma
WHEN	Friday, 21 st October 2011; 14.00-18.00
WHERE	Training Room Venture Center 100 NCL Innovation Park Dr. Homi Bhabha Road, Pune- 411008
CONTACT	Deepak Sarda IP Facilitation Center (IPFACE) 100, NCL Innovation Park, Dr. Homi Bhabha Road Pune - 411008 Phone: +91-20-64011024/25865876 Email: ipassociate@ipface.org
COST	Corporate/Large or Medium enterprises-1000/- Individual/ Micro and small enterprises -800/- Students with valid ID card; NCL, IISER and URDIP staff/students -200/- Free for IPFACE members, Resident Beneficiaries at VC (current and past).



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INTRODUCTION

The Leahy-Smith America Invents Act (AIA) is a newly enacted law in the United States. It is said that the AIA represents the most significant change to the U.S. patent system since 1952. The key changes brought about by the Act include - change over to a "first to invent" to a "first to file" system, elimination of interference proceedings, changes best mode practice, and allows post-grant opposition. The new law aims to harmonize the American patent process with the rest of the world and to make it more efficient and predictable. Knowledge of these changes is crucial for any inventor or entrepreneur or organization or IP professional who wishes to file/prosecute/analyze/license a US patent and/or commercialize technology in the US. This workshop is a "must attend" for Indian patent professionals since filing/prosecution/ licensing US patents is the most important segment of international patent practice. This workshop is a "must attend" for pharma/biotech and other high tech companies wishing to sell their products in the US market which represents roughly 50% of the global market.

OUTLINE

- Brief introduction to US Patent Law and procedures
- Background and motivation for changes to US Patent Law
- Leahy-Smith America Invents Act
 - Overview
 - First to file system
 - Post grant review
 - Fee related provisions
 - Prioritized examination
 - Best mode changes
 - Others
- Implications and new filing/ prosecution/ litigation/ commercialization strategies

OBJECTIVE

- This workshop aims to provide an introduction to the recent Leahy-Smith America Invents Act 2011, discuss key features and changes and their implications on filing/prosecution/litigation commercialization strategy.

WHO IS IT FOR

- Companies/organizations/ inventors filing patents in the US
- IP professionals / patent agents
- Staff of IP/ technology management departments
- Advocates/ law firms/ LPOs/ KPOs
- Students of law/IP law/pharma/ biopharma

WORKSHOP SCHEDULE

Date	Timing	Session
Friday, 21 st October 2011	13.45-14.00	Registration
	14.00-15.00	Brief introduction to US Patent Law and procedures Background and motivation for changes to US Patent Law
	15.00-15.20	Snacks and tea
	15.20-17.00	Leahy-Smith America Invents Act <ul style="list-style-type: none"> • Overview • First to file system • Post grant review • Fee related provisions • Prioritized examination • Best mode changes • Others
	17.00-17.45	Implications and new filing/ prosecution/ litigation/ commercialization strategies ; Q&A/ Discussions

FACULTY



Hasit Seth

Hasit Seth is a director with cofluence (www.cofluence.com), which creates content to communicate ideas. cofluence creates eLearning course material in the fields of IP, law, business strategy and negotiations. cofluence also advises on IP strategy. cofluence has helped several national government laboratories, startups and corporations to optimize invention creation, filing costs, IP portfolios and commercialize their IP portfolios.

Hasit has over last 12 years worked with IP law firms in the US, licensing companies and courts in India. He last worked as Asia Patent Manager with EATON, a large US industrial company. Hasit has contributed a chapter to "Software Patents Worldwide" published by Kluwer Law. He is also a visiting scientist at the National Chemical Laboratory in their IP group. He has experience in the legal field covering the whole value-chain of patents from invention (at EATON), drafting and litigation (US law firms Harness Dickey, F.Chau), licensing (at IPVALUE). Previously, he was a practicing counsel at the BOMBAY HIGH COURT. He has worked through law firms in US for clients like SIEMENS, IBM, PANASONIC, TRW, SEIKO-EPSON, LG, SAMSUNG and others. Until recently, he was the Asia Pacific IP counsel for EATON, a large diversified manufacturing MNC.

Education: B.Sc, LL.B, LL.M (Commercial Law, Mumbai Uni., Gold Medal), LL.M in IP (FPLC, USA), Member of the New York Bar.



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COURSE INCLUDES

Course includes

- Priority downloadable slides and handouts
- Free reference membership to Venture Center Library

ABOUT IPFACE

IPFACE aims to promote awareness and adoption of intellectual property rights amongst entrepreneurs and MSMEs in India while also making accessible high-quality IP services and resources. IPFACE is a project of the Venture Center supported by the Ministry of Micro, Small and Medium Enterprises, Government of India and National Chemical Laboratory, Council of Scientific and Industrial Research, India.

For more information about IPFACE services, visit www.ipface.org